

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	gate adj oxide with "2.5" adj (Angstrom or "Ang" or "A")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 19:58
L2	581	438/775-777.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 19:59
L3	357	438/769.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:00
L4	2	2 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:01
L5	0	3 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:05
L6	0	2 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:05
L7	0	3 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:05
L8	0	3 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:06

L9	0	2 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:06
L10	2956	Sandhu.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:10
L11	126	L10 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:10
L12	3	L10 and (gate adj oxide with ("5" adj Angstrom))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:11
L13	177	257/405.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L14	1079	257/410.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L15	1110	257/411.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L16	0	13 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L17	0	13 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17

L18	0	13 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L19	0	13 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:17
L20	0	13 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L21	0	13 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L22	2	14 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L23	2	14 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L24	0	14 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L25	0	14 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:18
L26	0	14 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:19

L27	0	14 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:19
L28	0	15 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:20
L29	0	15 and gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:20
L30	0	15 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:21
L31	0	15 and gate adj oxide with ".5" adj nanometers	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:21
L32	0	15 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:21
L33	0	15 and gate adj oxide with ".5" with "nm"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 20:21
S1	13	gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:03
S2	59	(gate adj oxide or (silicon adj dioxide)) with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:03

S3	88	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:04
S4	20	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:17
S5	0	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same ((nitrogen or "N" or nitride) with half)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:05
S6	189	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:25
S7	24	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:25
S8	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with (("2.5" adj Angstrom) or ("0.25" adj nanometer)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:23
S9	3	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with upper)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:24

S10	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with "50%")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:24
S11	2554	Sandhu.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:55
S13	0	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:25
S14	0	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:27
S15	0	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:28
S16	22	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S17	4	"6660658"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:47

S18	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/01/21 13:34
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		"6362085"   "6399445"   "6399448" "6410991"   "6413881"   "6436771" "6450116"   "6482690"   "6492690"). PN.				
S19	2	("6660658").URPN.	USPAT	OR	OFF	2007/01/21 13:43
S20	5	"6660657"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:43
S21	84	("20030034518"   "4605447"   "5026574" "5032545"   "5164331"   "5254489" "5258333"   "5318924"   "5330920" "5334554"   "5378645"   "5382533" "5436481"   "5445999"   "5449631" "5464792"   "5500380"   "5518946" "5518958"   "5596218"   "5612558" "5619057"   "5620908"   "5633036" "5663036"   "5663077"   "5674788" "5685949"   "5716864"   "5719083" "5760475"   "5763922"   "5834372" "5837592"   "5837598"   "5840610" "5861651"   "5885877"   "5939750" "5960289"   "5960302"   "5970345" "5972783"   "5972800"   "5994749" "5998253"   "6033998"   "6054396" "6057220"   "6080629"   "6080682" "6087229"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/01/21 13:44



		"6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"   "6362085"   "6399445"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S22	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/01/21 13:45

		"5972783"   "5972800"   "5994749" "5998253"   "6033998"   "6054396" "6057220"   "6080629"   "6080682" "6087229"   "6091109"   "6091110" "6093661"   "6110780"   "6110842" "6114203"   "6136636"   "6140187" "6146948"   "6174821"   "6184110" "6197701"   "6201303"   "6207532" "6207586"   "6225167"   "6228701" "6232244"   "6255703"   "6268296" "6274442"   "6297162"   "6323114" "6331492"   "6362085"   "6399445" "6410991"   "6413881"   "6436771" "6450116"   "6482690"   "6492690"). PN.				
S23	3	("6660657").URPN.	USPAT	OR	OFF	2007/01/21 13:45
S24	2	"20020098710"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:48
S25	406	438/775.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:48
S26	515	438/775-777.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:48

S27	1438	438/787-788.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S28	1081	438/770.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S29	214	438/532.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S30	1181	438/653.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S31	313	438/657.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:49
S32	0	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:53
S33	1	S25 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:50
S34	1	S26 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:50

S35	1	S27 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:51
S36	2	S28 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:51
S37	0	S29 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:51
S38	0	S30 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:56
S39	1	S31 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:51
S40	0	S11 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "Å") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:53

S41	0	S25 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:54
S42	0	S26 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:54
S43	0	S27 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:54
S44	0	S28 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:54
S45	0	S29 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:55
S46	0	S30 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:56

S47	0	S31 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:55
S48	34237	Moore.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:56
S49	0	S48 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:56
S50	0	S48 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:57
S51	1245	Rueger.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:56
S52	0	S51 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:57
S53	0	S51 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/21 13:57

S54	13	gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S55	60	(gate adj oxide or (silicon adj dioxide)) with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S56	90	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S57	20	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S58	0	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same ((nitrogen or "N" or nitride) with half)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S59	194	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S60	24	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12

S61	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with (("2.5" adj Angstrom) or ("0.25" adj nanometer)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S62	3	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with upper)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S63	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with "50%")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S64	2610	Sandhu.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S65	108	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S66	0	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12



S67	0	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S68	0	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S69	22	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5") or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S70	4	"6660658"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S71	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/03/04 21:12

		"5885877"     "5939750"   "5960289"   "5960302"     "5970345"   "5972783"   "5972800"     "5994749"   "5998253"   "6033998"     "6054396"   "6057220"   "6080629"     "6080682"   "6087229"   "6091109"     "6091110"   "6093661"   "6110780"     "6110842"   "6114203"   "6136636"     "6140187"   "6146948"   "6174821"     "6184110"   "6197701"   "6201303"     "6207532"   "6207586"   "6225167"     "6228701"   "6232244"   "6255703"     "6268296"   "6274442"   "6297162"     "6323114"   "6331492"   "6362085"     "6399445"   "6399448"   "6410991"     "6413881"   "6436771"   "6450116"     "6482690"   "6492690"). PN.				
S72	2	("6660658").URPN.	USPAT	OR	OFF	2007/03/04 21:12
S73	5	"6660657"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12

S74	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/03/04 21:12
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		"6331492"   "6362085"   "6399445"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S75	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/03/04 21:12

		"6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"   "6362085"   "6399445"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S76	3	("6660657").URPN.	USPAT	OR	OFF	2007/03/04 21:12
S77	2	"20020098710"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S78	412	438/775.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S79	523	438/775-777.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S80	1451	438/787-788.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S81	1089	438/770.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S82	214	438/532.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12

S83	1187	438/653.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S84	314	438/657.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S85	0	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S86	1	S78 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S87	1	S79 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S88	1	S80 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S89	2	S81 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12

S90	0	S82 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S91	0	S83 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S92	1	S84 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S93	0	S64 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "Å") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S94	0	S78 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "Å") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S95	0	S79 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "Å") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12

S96	0	S80 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S97	0	S81 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:15
S98	0	S82 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S99	0	S83 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:15
S100	0	S84 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:15
S101	34440	Moore.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S102	0	S101 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12



S103	0	S101 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S104	1253	Rueger.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S105	0	S104 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S106	0	S104 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S107	42849	S54 S55 S56 S57 S58 S59 S60 S61 S62 S63 S64 S65 S66 S67 S68 S69 S70 S71 S72 S73 S74 S75 S76 S77 S78 S79 S80 S81 S82 S83 S84 S85 S86 S87 S88 S89 S90 S91 S92 S93 S94 S95 S96 S97 S98 S99 S100 S101 S102 S103 S104 S105 S106	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/04 21:12
S108	10	"6040249"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/16 23:02
S109	20	gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S110	76	(gate adj oxide or (silicon adj dioxide)) with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S111	113	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S112	24	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S113	1	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same ((nitrogen or "N" or nitride) with half)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S114	233	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S115	28	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S116	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with (("2.5" adj Angstrom) or ("0.25" adj nanometer)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S117	5	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with upper)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S118	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with "50%")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S119	2956	Sandhu.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S120	126	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S121	2	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S122	2	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S123	0	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S124	28	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5") or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S125	4	"6660658"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S126	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12

		"6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"   "6362085"   "6399445"   "6399448"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S127	2	("6660658").URPN.	USPAT	OR	OFF	2008/08/03 14:12
S128	7	"6660657"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S129	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12

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"5685949" |  
"5716864" | "5719083"  
"5760475" |  
"5763922" | "5834372"  
"5837592" |  
"5837598" | "5840610"  
"5861651" |  
"5885877" | "5939750"  
"5960289" |  
"5960302" | "5970345"  
"5972783" |  
"5972800" | "5994749"  
"5998253" |  
"6033998" | "6054396"  
"6057220" |  
"6080629" | "6080682"  
"6087229" |  
"6091109" | "6091110"  
"6093661" |  
"6110780" | "6110842"  
"6114203" |  
"6136636" | "6140187"  
"6146948" |  
"6174821" | "6184110"  
"6197701" |  
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"6232244" |  
"6255703" | "6268296"  
"6274442" |  
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"6331492" |  
"6362085" | "6399445"  
"6410991" |  
"6413881" | "6436771"  
"6450116" |  
"6482690" | "6492690").  
PN.

S130	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12
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		"6331492"   "6362085"   "6399445" "6410991"   "6413881"   "6436771" "6450116"   "6482690"   "6492690"). PN.				
S131	4	("6660657").URPN.	USPAT	OR	OFF	2008/08/03 14:12
S132	3	"20020098710"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S133	459	438/775.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S134	581	438/775-777.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S135	1592	438/787-788.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S136	1168	438/770.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S137	228	438/532.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S138	1304	438/653.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12



S139	326	438/657.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S140	2	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S141	1	S133 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S142	1	S134 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S143	1	S135 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S144	2	S136 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S145	0	S137 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S146	0	S138 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S147	1	S139 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S148	0	S119 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S149	0	S133 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S150	0	S134 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S151	0	S135 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S152	0	S136 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S153	0	S137 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S154	0	S138 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S155	0	S139 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S156	37919	Moore.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S157	0	S156 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S158	2	S156 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S159	1387	Rueger.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S160	0	S159 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A" or ("0.5" adj "nanometer"))) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S161	2	S159 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S162	20	gate adj oxide with "5" adj Angstrom	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S163	76	(gate adj oxide or (silicon adj dioxide)) with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S164	113	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S165	24	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S166	1	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) same ((nitrogen or "N" or nitride) with half)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S167	233	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S168	28	(gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S169	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with (("2.5" adj Angstrom) or ("0.25" adj nanometer)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S170	5	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with upper)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S171	0	((gate adj oxide) or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same ((nitrogen or "N" or nitride) with "50%")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S172	2956	Sandhu.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S173	126	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with ("5" adj Angstrom) or ("0.5" adj nanometer) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S174	2	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S175	2	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S176	0	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj nanometer)) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S177	28	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S178	4	"6660658"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S179	84	( "20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"   "5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12

		"6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"   "6362085"   "6399445"   "6399448"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S180	2	("6660658").URPN.	USPAT	OR	OFF	2008/08/03 14:12
S181	7	"6660657"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S182	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"   "5837598"   "5840610"   "5861651"   "5885877"   "5939750"   "5960289"   "5960302"   "5970345"   "5972783"   "5972800"   "5994749"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12



		"5998253"   "6033998"   "6054396"   "6057220"   "6080629"   "6080682"   "6087229"   "6091109"   "6091110"   "6093661"   "6110780"   "6110842"   "6114203"   "6136636"   "6140187"   "6146948"   "6174821"   "6184110"   "6197701"   "6201303"   "6207532"   "6207586"   "6225167"   "6228701"   "6232244"   "6255703"   "6268296"   "6274442"   "6297162"   "6323114"   "6331492"   "6362085"   "6399445"   "6410991"   "6413881"   "6436771"   "6450116"   "6482690"   "6492690"). PN.				
S183	84	("20030034518"   "4605447"   "5026574"   "5032545"   "5164331"   "5254489"   "5258333"   "5318924"   "5330920"   "5334554"   "5378645"   "5382533"   "5436481"   "5445999"   "5449631"   "5464792"   "5500380"   "5518946"   "5518958"   "5596218"   "5612558"   "5619057"   "5620908"   "5633036"   "5663036"   "5663077"   "5674788"   "5685949"   "5716864"   "5719083"   "5760475"   "5763922"   "5834372"   "5837592"	US-PGPUB; USPAT; USOCR	OR	OFF	2008/08/03 14:12

		"5837598"   "5840610" "5861651"   "5885877"   "5939750" "5960289"   "5960302"   "5970345" "5972783"   "5972800"   "5994749" "5998253"   "6033998"   "6054396" "6057220"   "6080629"   "6080682" "6087229"   "6091109"   "6091110" "6093661"   "6110780"   "6110842" "6114203"   "6136636"   "6140187" "6146948"   "6174821"   "6184110" "6197701"   "6201303"   "6207532" "6207586"   "6225167"   "6228701" "6232244"   "6255703"   "6268296" "6274442"   "6297162"   "6323114" "6331492"   "6362085"   "6399445" "6410991"   "6413881"   "6436771" "6450116"   "6482690"   "6492690"). PN.				
S184	4	("6660657").URPN.	USPAT	OR	OFF	2008/08/03 14:12
S185	3	"20020098710"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S186	459	438/775.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S187	581	438/775-777.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S188	1592	438/787-788.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S189	1168	438/770.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S190	228	438/532.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S191	1304	438/653.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S192	326	438/657.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S193	2	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S194	1	S186 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S195	1	S187 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S196	1	S188 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S197	2	S189 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S198	0	S190 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S199	0	S191 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S200	1	S192 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S201	0	S172 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S202	0	S186 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S203	0	S187 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S204	0	S188 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S205	0	S189 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S206	0	S190 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S207	0	S191 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S208	0	S192 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S209	37919	Moore.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S210	0	S209 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S211	2	S209 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S212	1387	Rueger.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

S213	0	S212 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj "A") or ("0.5" adj "nanometer")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S214	2	S212 and (gate adj oxide or (silicon adj dioxide) or "SiO.sub.2") with (("5" adj Angstrom) or ("0.5" adj "nm")) same (nitrogen or "N" or nitride)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S215	47211	S162 S163 S164 S165 S166 S167 S168 S169 S170 S171 S172 S173 S174 S175 S176 S177 S178 S179 S180 S181 S182 S183 S184 S185 S186 S187 S188 S189 S190 S191 S192 S193 S194 S195 S196 S197 S198 S199 S200 S201 S202 S203 S204 S205 S206 S207 S208 S209 S210 S211 S212 S213 S214	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12
S216	47211	S109 S110 S111 S112 S113 S114 S115 S116 S117 S118 S119 S120 S121 S122 S123 S124 S125 S126 S127 S128 S129 S130 S131 S132 S133 S134 S135 S136 S137 S138 S139 S140 S141 S142 S143 S144 S145 S146 S147 S148 S149 S150 S151 S152 S153 S154 S155 S156 S157 S158 S159 S160 S161 S162 S163 S164 S165 S166 S167 S168 S169 S170 S171 S172 S173 S174 S175 S176 S177 S178 S179 S180 S181 S182 S183 S184 S185 S186 S187 S188	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:12

		S189 S190 S191 S192 S193 S194 S195 S196 S197 S198 S199 S200 S201 S202 S203 S204 S205 S206 S207 S208 S209 S210 S211 S212 S213 S214 S215				
S217	74	gate adj oxide with "5" adj (Angstrom or "Ang" or "A")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:24
S218	36	S217 and nitrogen	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/08/03 14:25

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